Didier Chaussende

List of Publications by Year in Descending Order

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The third column is the impact factor (IF) of the journal, and the fourth column is the number of citations of the article.

| 135 | 1,283 citations | 19 | 3 O |
|-------------|----------------------|---------|------------|
| papers | | h-index | g-index |
| 137 | 1,403 ext. citations | 1.6 | 4.08 |
| ext. papers | | avg, IF | L-index |

| # | Paper | IF | Citations |
|-----|---|---------------|-----------|
| 135 | A sessile drop approach for studying 4H-SiC/liquid silicon high-temperature interface reconstructions. <i>Journal of Materials Science</i> , 2022 , 57, 972 | 4.3 | 1 |
| 134 | In Situ Interferometry for ppm-Order Solubility Analysis at High Temperatures: A Case Study of Carbon Solubility in Molten Silicon. <i>Metallurgical and Materials Transactions B: Process Metallurgy and Materials Processing Science</i> , 2021 , 52, 2619 | 2.5 | |
| 133 | 3C[I4H[Iand 6HBiC crystal habitus and interfacial behaviours in high temperature Si-based solvents. <i>CrystEngComm</i> , 2020 , 22, 3489-3496 | 3.3 | 1 |
| 132 | SiC/Al4SiC4-Based Heterostructure Transistors. ACS Applied Electronic Materials, 2020, 2, 3001-3007 | 4 | 1 |
| 131 | Revisiting the Site-Competition Doping of 4H-SiC: Cases of N and Al. <i>Materials Science Forum</i> , 2020 , 1004, 96-101 | 0.4 | |
| 130 | Monte Carlo Simulations of Electron Transport Characteristics of Ternary Carbide Al4SiC4. <i>ACS Applied Energy Materials</i> , 2019 , 2, 715-720 | 6.1 | 2 |
| 129 | Structural, Electronic and Vibrational Properties of Al4C3. <i>Physica Status Solidi (B): Basic Research</i> , 2019 , 256, 1900037 | 1.3 | 3 |
| 128 | Understanding Al incorporation into 4H-SiC during epitaxy. <i>Journal of Crystal Growth</i> , 2019 , 507, 338-34 | 13 1.6 | 3 |
| 127 | Silicon carbide 2019 , 129-179 | | 5 |
| 126 | The (001) 3C SiC surface termination and band structure after common wet chemical etching procedures, stated by XPS, LEED, and HREELS. <i>Applied Surface Science</i> , 2018 , 427, 480-485 | 6.7 | 14 |
| 125 | A new model for in situ nitrogen incorporation into 4H-SiC during epitaxy. <i>Scientific Reports</i> , 2017 , 7, 43069 | 4.9 | 13 |
| 124 | (001) 3C SiC/Ni contact interface: In situ XPS observation of annealing induced Ni2Si formation and the resulting barrier height changes. <i>Applied Surface Science</i> , 2017 , 400, 6-13 | 6.7 | 9 |
| 123 | Vaporization and condensation in the Al4C3-SiC system. <i>Journal of the European Ceramic Society</i> , 2017 , 37, 4475-4482 | 6 | 8 |
| 122 | Effect of Aluminum during the High Temperature Solution Growth of Si-Face 4H-SiC. <i>Materials Science Forum</i> , 2016 , 858, 37-40 | 0.4 | 2 |
| 121 | Experimental Investigation of the Seeding Stage during SiC Solution Growth Using Si and Al-Si Solvents. <i>Materials Science Forum</i> , 2016 , 858, 81-84 | 0.4 | 1 |
| 120 | A first step toward bridging silicon carbide crystal properties and physical chemistry of crystal growth. <i>CrystEngComm</i> , 2016 , 18, 2119-2124 | 3.3 | 7 |
| 119 | Analysis of Macrostep Formation during Top Seeded Solution Growth of 4H-SiC. <i>Crystal Growth and Design</i> , 2016 , 16, 3231-3236 | 3.5 | 9 |

(2013-2015)

| 118 | Photoelectrical Parameters of a PVT Grown Bulk 15R-SiC Crystal at Different Stages of Growth. Materials Science Forum, 2015 , 821-823, 253-256 | 0.4 | |
|-----|---|------|----|
| 117 | Nitrogen Incorporation during Seeded Sublimation Growth of 4H-SiC and 6H-SiC. <i>Materials Science Forum</i> , 2015 , 821-823, 60-63 | 0.4 | 2 |
| 116 | Assessment of SiC Crystal Chemistry during the PVT Growth Process: Coupled Numerical Modeling and Thermodynamics Approach. <i>Materials Science Forum</i> , 2015 , 821-823, 96-99 | 0.4 | |
| 115 | Synthesis and Characterization of Al4SiC4: A NewlWide Band Gap Semiconductor Material. <i>Materials Science Forum</i> , 2015 , 821-823, 974-977 | 0.4 | 5 |
| 114 | Macroscopic Approach to the Nucleation and Propagation of Foreign Polytype Inclusions during Seeded Sublimation Growth of Silicon Carbide. <i>Crystal Growth and Design</i> , 2015 , 15, 156-163 | 3.5 | 2 |
| 113 | Open Issues in SiC Bulk Growth. <i>Materials Science Forum</i> , 2014 , 778-780, 3-8 | 0.4 | 3 |
| 112 | Interaction between Vapor Species and Graphite Crucible during the Growth of SiC by PVT. <i>Materials Science Forum</i> , 2014 , 778-780, 31-34 | 0.4 | 1 |
| 111 | Effect of Facet Occurrence on Polytype Destabilization during Bulk Crystal Growth of SiC by Seeded Sublimation. <i>Materials Science Forum</i> , 2014 , 778-780, 13-16 | 0.4 | 3 |
| 110 | Ge Mediated Surface Preparation for Twin Free 3C-SiC Nucleation and Growth on Low Off-Axis 4H-SiC Substrate. <i>ECS Journal of Solid State Science and Technology</i> , 2014 , 3, P285-P292 | 2 | 8 |
| 109 | Comparison of Thermodynamic Databases for the Modeling of SiC Growth by PVT. <i>Materials Science Forum</i> , 2014 , 778-780, 35-38 | 0.4 | 1 |
| 108 | Spiral Step Dissociation on PVT Grown SiC Crystals. <i>Materials Science Forum</i> , 2014 , 778-780, 39-42 | 0.4 | 1 |
| 107 | Nondestructive Evaluation of Photoelectrical Properties of a PVT Grown Bulk 15R-SiC Crystal. <i>Materials Science Forum</i> , 2014 , 806, 65-69 | 0.4 | 1 |
| 106 | Double-Position-Boundaries Free 3C-SiC Epitaxial Layers Grown on On-Axis 4H-SiC. <i>ECS Journal of Solid State Science and Technology</i> , 2014 , 3, P75-P81 | 2 | 15 |
| 105 | Electromagnetic Enhancement of Carbon Transport in SiC Solution Growth Process: A Numerical Modeling Approach. <i>Materials Science Forum</i> , 2014 , 778-780, 71-74 | 0.4 | 7 |
| 104 | Interface Shape: A Possible Cause of Polytypes Destabilization during Seeded Sublimation Growth of 15R-SiC. <i>Materials Science Forum</i> , 2014 , 806, 61-64 | 0.4 | 4 |
| 103 | On Photoelectrical Properties of 6H-SiC Bulk Crystals PVT-Grown on 6H- and 4H-SiC Substrates. <i>Materials Science Forum</i> , 2014 , 778-780, 305-308 | 0.4 | 3 |
| 102 | Ge Assisted SiC Epitaxial Growth by CVD on SiC Substrate. <i>Materials Science Forum</i> , 2014 , 778-780, 187- | 1924 | 5 |
| 101 | 3C-SiC Heteroepitaxy on Hexagonal SiC Substrates. <i>Materials Science Forum</i> , 2013 , 740-742, 257-262 | 0.4 | 6 |

| 100 | Comparison of the spiral growth modes of silicon-face and carbon-face silicon carbide crystals. Journal of Crystal Growth, 2013 , 384, 129-134 | 1.6 | 6 |
|-----|---|-----|----|
| 99 | High temperature solution growth and characterization of Cr2AlC single crystals. <i>Journal of Crystal Growth</i> , 2013 , 384, 88-95 | 1.6 | 34 |
| 98 | Revealing the electronic band structure of trilayer graphene on SiC: An angle-resolved photoemission study. <i>Physical Review B</i> , 2013 , 88, | 3.3 | 61 |
| 97 | Epitaxial graphene morphologies probed by weak (anti)-localization. <i>Journal of Applied Physics</i> , 2013 , 113, 083715 | 2.5 | 7 |
| 96 | Absence of Back Stress Effect in the PVT Growth of 6H Silicon Carbide. <i>Materials Science Forum</i> , 2013 , 740-742, 48-51 | 0.4 | |
| 95 | Polytypic transformations in SiC: Diffuse x-ray scattering and Monte Carlo simulations. <i>Physical Review B</i> , 2013 , 88, | 3.3 | 6 |
| 94 | Diffuse X-ray scattering from partially transformed 3CBiC single crystals. <i>Nuclear Instruments & Methods in Physics Research B</i> , 2012 , 284, 19-22 | 1.2 | 2 |
| 93 | Modeling of the Growth Rate during Top Seeded Solution Growth of SiC Using Pure Silicon as a Solvent. <i>Crystal Growth and Design</i> , 2012 , 12, 909-913 | 3.5 | 20 |
| 92 | Combined experimental and computational study of the recrystallization process induced by electronic interactions of swift heavy ions with silicon carbide crystals. <i>Physical Review B</i> , 2012 , 86, | 3.3 | 69 |
| 91 | Critical assessment of birefringence imaging of dislocations in 6H silicon carbide. <i>Journal of Crystal Growth</i> , 2012 , 354, 202-207 | 1.6 | 6 |
| 90 | Large Area Quasi-Free Standing Monolayer Graphene on 3C-SiC(111). <i>Materials Science Forum</i> , 2012 , 717-720, 617-620 | 0.4 | 3 |
| 89 | Fabrication of SiC Nanopillars by Inductively Coupled SF6/O2 Plasma. <i>Materials Science Forum</i> , 2012 , 711, 66-69 | 0.4 | 2 |
| 88 | On the Stability of 3C-SiC Single Crystals at High Temperatures. <i>Materials Science Forum</i> , 2012 , 717-720, 493-496 | 0.4 | |
| 87 | Growth Rate Prediction in SiC Solution Growth Using Silicon as Solvent. <i>Materials Science Forum</i> , 2012 , 717-720, 69-72 | 0.4 | 2 |
| 86 | Application of an axial next-nearest-neighbor Ising model to the description of Mn+1AXn phases. <i>Physical Review B</i> , 2012 , 85, | 3.3 | 2 |
| 85 | Identification of the Basal Plane Component of the Burgers Vector of Small Dislocations in 6H SiC Using Birefringence Microscopy. <i>Materials Science Forum</i> , 2012 , 717-720, 331-334 | 0.4 | |
| 84 | Raman scattering from Ti3SiC2 single crystals. <i>Applied Physics Letters</i> , 2011 , 98, 081912 | 3.4 | 40 |
| 83 | Growth and Characterization of Thick Polycrystalline AlN Layers by HTCVD. <i>Journal of the Electrochemical Society</i> , 2011 , 158, H328 | 3.9 | 7 |

(2010-2011)

| 82 | Optical Investigation of Defect Filtering Effects in Bulk 3C-SiC Crystals Grown by the CF-PVT Method Using a Necking Technique. <i>Materials Science Forum</i> , 2011 , 679-680, 169-172 | 0.4 | |
|----|---|-----|----|
| 81 | Formation process of 3C-SiC on 6H-SiC (0001) by low-temperature solution growth in SiBc C system. <i>Journal of Crystal Growth</i> , 2011 , 335, 94-99 | 1.6 | 15 |
| 80 | Investigation on AlN epitaxial growth and related etching phenomenon at high temperature using high temperature chemical vapor deposition process. <i>Journal of Crystal Growth</i> , 2011 , 335, 17-24 | 1.6 | 17 |
| 79 | From Si nanowire to SiC nanotube. <i>Journal of Nanoparticle Research</i> , 2011 , 13, 5425-5433 | 2.3 | 22 |
| 78 | Aluminum nitride homoepitaxial growth on polar and non-polar AlN PVT substrates by high temperature CVD (HTCVD). <i>Physica Status Solidi C: Current Topics in Solid State Physics</i> , 2011 , 8, 2019-20 |)21 | 11 |
| 77 | Kinetics of the 3C-6H polytypic transition in 3C-SiC single crystals: A diffuse X-ray scattering study. <i>Journal of Applied Physics</i> , 2011 , 110, 053508 | 2.5 | 13 |
| 76 | Large area quasi-free standing monolayer graphene on 3C-SiC(111). <i>Applied Physics Letters</i> , 2011 , 99, 081904 | 3.4 | 54 |
| 75 | Morphological instabilities induced by foreign particles and Ehrlich-Schwoebel effect during the two-dimensional growth of crystalline Ti3SiC2. <i>Physical Review B</i> , 2011 , 83, | 3.3 | 18 |
| 74 | Quality Investigation of 3C-SiC Crystals Grown by CF-PVT Technique. <i>Materials Science Forum</i> , 2011 , 679-680, 20-23 | 0.4 | |
| 73 | TEM and LTPL Investigations of 3C-SiC Layers Grown by LPE on (100) and (111) 3C-SiC Seeds. <i>Materials Science Forum</i> , 2010 , 645-648, 383-386 | 0.4 | 1 |
| 72 | Characterization and modelling of the ion-irradiation induced disorder in 6H-SiC and 3C-SiC single crystals. <i>Journal Physics D: Applied Physics</i> , 2010 , 43, 455408 | 3 | 74 |
| 71 | Improvements of the Continuous Feed-Physical Vapor Transport Technique (CF-PVT) for the Seeded Growth of 3C-SiC Crystals. <i>Materials Science Forum</i> , 2010 , 645-648, 63-66 | 0.4 | 2 |
| 70 | Further Evidence of Nitrogen Induced Stabilization of 3C-SiC Polytype during Growth from a Si-Ge Liquid Phase. <i>Materials Science Forum</i> , 2010 , 645-648, 163-166 | 0.4 | 3 |
| 69 | Is the Liquid Phase a Viable Approach for Bulk Growth of 3C-SiC?. <i>Materials Science Forum</i> , 2010 , 645-648, 67-70 | 0.4 | 5 |
| 68 | Study of the Spontaneous Nucleation of 3C-SiC Single Crystals Using CF-PVT Technique. <i>Materials Science Forum</i> , 2010 , 645-648, 55-58 | 0.4 | 3 |
| 67 | Heavily p-Type Doping of Bulk 6H-SiC and 3C-SiC Grown from Al-Si Melts. <i>Materials Science Forum</i> , 2010 , 645-648, 59-62 | 0.4 | 3 |
| 66 | Coupled heat transfer and fluid dynamics modeling of high-temperature SiC solution growth. <i>Journal of Crystal Growth</i> , 2010 , 312, 155-163 | 1.6 | 49 |
| 65 | Evolution of 3C-SiC islands nucleated from a liquid phase on Si face EsiC substrates. <i>Thin Solid Films</i> , 2010 , 518, 4234-4241 | 2.2 | 5 |

| 64 | Micropipe-induced birefringence in 6H silicon carbide. <i>Journal of Applied Crystallography</i> , 2010 , 43, 122 | -1338 | 15 |
|----|--|-------|----|
| 63 | Quantitative analysis of diffuse X-ray scattering in partially transformed 3C-SiC single crystals. <i>Journal of Applied Crystallography</i> , 2010 , 43, 867-875 | 3.8 | 8 |
| 62 | The 3C-6H polytypic transition in SiC as revealed by diffuse x-ray scattering. <i>Applied Physics Letters</i> , 2009 , 94, 201904 | 3.4 | 13 |
| 61 | Influence of the N/Al Ratio in the Gas Phase on the Growth of AlN by High Temperature Chemical Vapor Deposition (HTCVD). <i>Materials Science Forum</i> , 2009 , 615-617, 987-990 | 0.4 | 2 |
| 60 | High-speed Growth and Characterization of Polycrystalline AlN Layers by High Temperature Chemical Vapor Deposition (HTCVD). <i>ECS Transactions</i> , 2009 , 25, 323-326 | 1 | 3 |
| 59 | Optical Investigation of Electronic Properties in Bulk and Surface Region of Sublimation-Grown 3C-SiC Crystals. <i>Materials Science Forum</i> , 2009 , 615-617, 303-306 | 0.4 | 8 |
| 58 | Dislocation-Induced Birefringence in Silicon Carbide. <i>Materials Science Forum</i> , 2009 , 615-617, 271-274 | 0.4 | |
| 57 | Top Seeded Solution Growth of 3C-SiC Single Crystals. <i>Materials Science Forum</i> , 2009 , 615-617, 41-44 | 0.4 | 6 |
| 56 | Nitrogen Doping of 3C-SiC Single Crystals Grown by CF-PVT. <i>Materials Science Forum</i> , 2009 , 615-617, 45-48 | 0.4 | 1 |
| 55 | Effects of Temperature and Heating Rate on the Precipitation of 3C-SiC Islands on 4H-SiC(0001) from a Liquid Phase. <i>Materials Science Forum</i> , 2009 , 615-617, 193-196 | 0.4 | |
| 54 | Defect-induced polytype transformations in LPE grown SiC epilayers on (1 1 1) 3C-SiC seeds grown by VLS on 6H-SiC. <i>Physica B: Condensed Matter</i> , 2009 , 404, 4727-4730 | 2.8 | 1 |
| 53 | A TEM study of in-grown stacking faults in 3C-SiC layers grown by CF-PVT on 4H-SiC substrates. <i>Physica B: Condensed Matter</i> , 2009 , 404, 4749-4751 | 2.8 | 7 |
| 52 | Study of the 3C-SiC nucleation from a liquid phase on a C face 6H-SiC substrate. <i>Journal of Crystal Growth</i> , 2009 , 311, 2385-2390 | 1.6 | 16 |
| 51 | Thermodynamic and experimental investigations on the growth of thick aluminum nitride layers by high temperature CVD. <i>Journal of Crystal Growth</i> , 2009 , 311, 3371-3379 | 1.6 | 23 |
| 50 | Nucleation and Growth of 3C-SiC Single Crystals from the Vapor Phase. <i>Materials Science Forum</i> , 2009 , 615-617, 31-36 | 0.4 | 15 |
| 49 | Growth of Thick AlN Layers by High Temperature CVD (HTCVD). <i>Materials Science Forum</i> , 2008 , 600-603, 1269-1272 | 0.4 | 4 |
| 48 | Structural Characterization of CF-PVT Grown Bulk 3C-SiC. Materials Science Forum, 2008, 600-603, 67-70 | 0 0.4 | 1 |
| 47 | Comparative Study of Differently Grown 3C-SiC Single Crystals with Birefringence Microscopy. <i>Materials Science Forum</i> , 2008 , 600-603, 71-74 | 0.4 | 2 |

Silicon Carbide Growth: C/Si Ratio Evaluation and Modeling. Materials Science Forum, 2008, 600-603, 83-88.4 46 Experimental investigation of different configurations for the seeded growth of SiC crystals via a 1.3 45 VLS mechanism. Crystal Research and Technology, 2008, 43, 374-380 Prospects for 3C-SiC bulk crystal growth. Journal of Crystal Growth, 2008, 310, 976-981 1.6 44 35 Characterization of stacking faults in thick 3C-SiC crystals using high-resolution diffuse X-ray 1.6 43 scattering. Journal of Crystal Growth, 2008, 310, 982-987 Status of SiC bulk growth processes. Journal Physics D: Applied Physics, 2007, 40, 6150-6158 42 3 21 High SiC Growth Rate Obtained by Vapour-Liquid-Solid Mechanism. Materials Science Forum, 2007, 41 0.4 4 556-557, 105-108 How to Grow 3C-SiC Single Domain on EsiC(0001) by Vapor-Liquid-Solid Mechanism. Materials 40 0.4 3 Science Forum, **2007**, 556-557, 187-190 Mechanism of Orientation Selection for the Growth Of (111) Twin Boundary Free 3C-SiC Single 39 0.4 Crystals on Hexagonal Basis. Materials Science Forum, 2007, 556-557, 199-202 Thermodynamic Aspects of the Growth of SiC Single Crystals using the CF-PVT Process. Chemical 38 14 Vapor Deposition, 2006, 12, 541-548 Silicon Carbide Growth: C/Si Ratio Evaluation and Modeling. Materials Research Society Symposia 37 *Proceedings*, **2006**, 911, 2 Characterization of Bulk 3C-SiC Single Crystals Grown on 4H-SiC by the CF-PVT Method. Materials 36 0.4 12 Science Forum, 2006, 527-529, 99-102 Gas Fed Top-Seeded Solution Growth of Silicon Carbide. Materials Science Forum, 2006, 527-529, 111-1140.4 35 Single-Domain 3C-SiC Epitaxially Grown on 6H-SiC by the VLS Mechanism. Materials Science Forum, 6 0.4 34 2006, 527-529, 287-290 In Situ Observation of Mass Transfer in the CF-PVT Growth Process by X-Ray Imaging. Materials 33 0.4 Science Forum, 2006, 527-529, 63-66 X-ray diffuse scattering from stacking faults in thick 3C-SiC single crystals. Applied Physics Letters, 32 25 3.4 2006, 89, 091902 Growth of AlN and AlN-SiC Solid Solution by Sublimation Method. Materials Science Forum, 2006, 0.4 31 527-529, 1501-1504 Characterization of a 3C-SiC Single Domain Grown on 6H-SiC(0001) by a Vapor liquid Bolid 30 3.5 27 Mechanism. Crystal Growth and Design, 2006, 6, 2598-2602 High-Temperature Nucleation of Cubic Silicon Carbide on (0001) Hexagonal-SiC Nominal Surfaces. 26 29 3.5 Crystal Growth and Design, **2006**, 6, 2788-2794

| 28 | High temperature processing of poly-SiC substrates from the vapor phase for wafer-bonding. <i>Surface and Coatings Technology</i> , 2006 , 201, 4014-4020 | 4.4 | 4 |
|----|--|--------------|----|
| 27 | Large Area DPB Free (111) ESiC Thick Layer Grown on (0001) ESiC Nominal Surfaces by the CF-PVT Method. <i>Materials Science Forum</i> , 2005 , 483-485, 225-228 | 0.4 | 24 |
| 26 | Control of the Supersaturation in the CFBVT Process for the Growth of Silicon Carbide Crystals: Research and Applications. <i>Crystal Growth and Design</i> , 2005 , 5, 1539-1544 | 3.5 | 38 |
| 25 | Progress and Limits of the Numerical Simulation of SiC Bulk and Epitaxy Growth Processes. <i>Materials Science Forum</i> , 2005 , 483-485, 3-8 | 0.4 | 3 |
| 24 | Study of 3C-SiC nucleation on (0 0 0 1) 6H-SiC nominal surfaces by the CF-PVT method. <i>Journal of Crystal Growth</i> , 2005 , 275, e609-e613 | 1.6 | 12 |
| 23 | Characterization of Thick 2-Inch 4H-SiC Layers Grown by the Continuous Feed-Physical Vapor Transport Method. <i>Materials Science Forum</i> , 2004 , 457-460, 91-94 | 0.4 | 6 |
| 22 | In Situ SiC Feeding by Chemical Vapor Deposition for Bulk Growth. <i>Materials Science Forum</i> , 2004 , 457-460, 139-142 | 0.4 | |
| 21 | Wettability Study of SiC in Correlation with XPS Analysis. <i>Materials Science Forum</i> , 2004 , 457-460, 423-4 | 26 .4 | 2 |
| 20 | Comparison between Various Chemical Systems for the CVD Step in the CF-PVT Crystal Growth Method. <i>Materials Science Forum</i> , 2004 , 457-460, 135-138 | 0.4 | 2 |
| 19 | Electron Back Scattering Diffraction (EBSD) as a Tool for the Investigation of 3C-SiC Nucleation and Growth on 6H or 4H. <i>Materials Science Forum</i> , 2004 , 457-460, 387-390 | 0.4 | 10 |
| 18 | Vapor phase techniques for the fabrication of homoepitaxial layers of silicon carbide: process modeling and characterization. <i>Applied Surface Science</i> , 2003 , 212-213, 177-183 | 6.7 | 3 |
| 17 | Continuous Feed Physical Vapor Transport. <i>Journal of the Electrochemical Society</i> , 2003 , 150, G653 | 3.9 | 25 |
| 16 | SiC Homoepitaxial Growth at Low Temperature by VaporlliquidBolid Mechanism in AlBi Melt. <i>Crystal Growth and Design</i> , 2003 , 3, 285-287 | 3.5 | 11 |
| 15 | A Study of HTCVD Renewing of the SiC Polycrystalline Source during the PVT Process. <i>Materials Science Forum</i> , 2003 , 433-436, 87-90 | 0.4 | 1 |
| 14 | Heat Transfer Modeling of a New Crystal Growth Process. <i>Materials Science Forum</i> , 2003 , 433-436, 103- | 1064 | 1 |
| 13 | Investigation of Defects in 4H-SiC by Synchrotron Topography, Raman Spectroscopy Imaging and Photoluminescence Spectroscopy Imaging. <i>Materials Science Forum</i> , 2003 , 433-436, 265-268 | 0.4 | 2 |
| 12 | Towards a Continuous Feeding of the PVT Growth Process: an Experimental Investigation. <i>Materials Science Forum</i> , 2003 , 433-436, 25-28 | 0.4 | 2 |
| 11 | A comprehensive study of SiC growth processes in a VPE reactor. <i>Thin Solid Films</i> , 2002 , 402, 83-89 | 2.2 | 43 |

LIST OF PUBLICATIONS

| 10 | VapourIlquidIolid mechanism for the growth of SiC homoepitaxial layers by VPE. <i>Journal of Crystal Growth</i> , 2002 , 234, 63-69 | 1.6 | 12 |
|----|--|--------------|----|
| 9 | Study of the interaction between graphite and Al-Si melts for the growth of crystalline silicon carbide. <i>Journal of Materials Science</i> , 2002 , 37, 3299-3306 | 4.3 | 17 |
| 8 | Effect of the Si Droplet Size on the VLS Growth Mechanism of SiC Homoepitaxial Layers. <i>Materials Science Forum</i> , 2002 , 389-393, 287-290 | 0.4 | 10 |
| 7 | Atomic-Step Observations on 6H- and 15R-SiC Polished Surfaces. <i>Materials Science Forum</i> , 2002 , 389-393, 729-732 | 0.4 | 11 |
| 6 | Thermochemistry of silicon carbide growth by chemical transport reactions. <i>Journal of Materials Science</i> , 2001 , 36, 335-342 | 4.3 | 3 |
| 5 | Aluminium-Silicon as a Melt for the Low Temperature Growth of SiC Crystals. <i>Materials Science Forum</i> , 2001 , 353-356, 85-90 | 0.4 | 9 |
| 4 | 3C-SiC Pseudosubstrates for the Growth of Cubic GaN. <i>Materials Science Forum</i> , 2000 , 338-342, 1467-16 | 470 4 | |
| 3 | Growth Mode and Kinetics of Atmospheric Pressure Chemical Vapour Deposition of EsiC on Si(100) Substrate. <i>Materials Science Forum</i> , 1998 , 264-268, 227-230 | 0.4 | 9 |
| 2 | Single-Domain 3C-SiC Epitaxially Grown on 6H-SiC by the VLS Mechanism. <i>Materials Science Forum</i> ,287- | 2904 | 3 |
| 1 | Chemical Vapor Deposition of 3C-SiC on [100] Oriented Silicon at Low Temperature & amp;lt; 1200°C for Photonic Applications. <i>Materials Science Forum</i> ,1062, 119-124 | 0.4 | 1 |